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Ninghua Zhu
Werner H. Hofmann
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Contents

vii	<i>Authors</i>
ix	<i>Symposium Committees</i>
xi	<i>Conference Committee</i>

SEMICONDUCTOR LASERS

9267 02	Novel InGaAlAs/InGaAlAs quantum well multimode-interferometer-Fabry-Perot laser diode (Invited Paper) [9267-1]
---------	---

VCSELS

9267 06	Nonlinear dynamics of polarization switching of a 1550-nm vertical-cavity surface-emitting laser under orthogonal optical injection [9267-5]
9267 07	Design of high-power and narrow divergence angle photonic crystal surface emitting lasers [9267-6]

OPTICAL INJECTION OF SEMICONDUCTOR LASERS

9267 08	Detailed comparison of performance of a Fabry-Perot semiconductor laser under both strong and weak injection (Invited Paper) [9267-7]
9267 09	Influence of the nonlinear gain on the stability limit of a semiconductor laser with optical feedback [9267-8]
9267 0A	High side-mode suppression ratio laser output by single sideband injection locking of semiconductor lasers [9267-9]
9267 0B	Dynamic behaviors of a broad-area diode laser with lateral-mode-selected external feedback [9267-10]

MICROWAVE PHOTONICS I

9267 0C	Fiber-connected position localization sensor networks (Invited Paper) [9267-11]
9267 0E	Photonic generation of phase-modulated microwave signals (Invited Paper) [9267-13]

MICROWAVE PHOTONICS II

- 9267 OH **Measuring high-frequency responses of an electro-optic phase modulator based on dispersion induced phase modulation to intensity modulation conversion (Invited Paper)** [9267-16]

OPTICAL COMMUNICATIONS

- 9267 OK **Behavioral modeling and digital compensation of nonlinearity in DFB lasers for multi-band directly modulated radio-over-fiber systems (Invited Paper)** [9267-19]
- 9267 OL **Super-Nyquist signal transmission and digital signal processing (Invited Paper)** [9267-21]

LASER APPLICATIONS II

- 9267 ON **Narrow linewidth 1.55 μ m directly modulated distributed-feedback laser (Invited Paper)** [9267-27]
- 9267 OO **An ultra-wide-band optical frequency comb generator based on semiconductor quantum dot F-P cavity (Best Student Paper Award)** [9267-29]

LASER APPLICATIONS I

- 9267 OP **Mid-infrared pulsed fiber lasers operating at 3 μ m region (Invited Paper)** [9267-22]
- 9267 OQ **Blue shift of laser mode in photonic crystal microcavity** [9267-23]
- 9267 OS **FPGA based design for real-time measurement of alpha** [9267-25]

POSTER SESSION

- 9267 OT **All-optical clock recovery for 100 Gb/s RZ-OOK signal after 25km transmission using a dual-mode beating DBR laser** [9267-20]
- 9267 OV **Validate the parameters in HITRAN through the experiment of H₂O based on direct absorption spectroscopy technology** [9267-30]
- 9267 OX **Numerical analysis of thermal effects in semiconductor disk laser with water cooling** [9267-32]
- 9267 OZ **Fabrication of InGaAs/InP DBR laser with butt-coupled passive waveguide utilizing selective wet etching** [9267-34]
- 9267 IO **MBE growth and fabrication of 2.0 μ m InGa(As)Sb/AlGaAsSb laser** [9267-35]
- 9267 IJ **Design and optimization of a widely tunable semiconductor laser for blood oxygenation and blood flow measurements** [9267-37]

- 9267 13 **An asymmetric sampled Bragg grating structure for improving semiconductor laser efficiency [9267-38]**
- 9267 14 **The effect of zinc diffusion on extinction ratio of MQW electroabsorption modulator integrated with DFB laser [9267-39]**
- 9267 15 **Tunable V-coupled-cavity semiconductor laser monolithically integrated with monitoring photodiodes using deeply etched reflective trenches [9267-40]**
- 9267 16 **One-dimensional photonic crystal lasers with narrow vertical divergence and wavelength stabilization [9267-41]**

Authors

Numbers in the index correspond to the last two digits of the six-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first four digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

An, Xin, 14	Pan, Shilong, 0C
Bian, Jing, 14	Pan, Yingjun, 0X
Cai, Haiwen, 0A	Peng, Xuebao, 08
Chen, Dijun, 0A	Peters, Frank H., 02
Chen, Hao, 0K	Petersen, Paul Michael, 0B
Chen, Jian-Jun, 06	Qi, A. Y., 07, 0Q
Chen, Wei, 0N, 0O	Qi, F., 07, 0Q
Chen, Xiangfei, 13	Qu, H. W., 16
Chi, Mingjun, 0B	Qu, Ronghui, 0A
Chi, Nan, 0L	Shao, Jie, 0V
Corbett, Brian, 02	Song, Guangyi, 12
Dai, Yitang, 0K	Song, Guofeng, 10
Deng, Haoyu, 12	Song, Yuzhi, 10
Fan, Yuanlong, 09	Sun, Wenhui, 0N, 0O
Fang, Wei, 0A	Tong, Jun, 0S
Fang, Zujie, 0A	Tong, Sheng, 0S
Feng, Yafei, 12	Wang, Baojun, 14
Feng, Z. G., 0Q	Wang, Gang, 13
Fu, Jianbin, 0C	Wang, Heng, 0H
Guo, Jin-Jin, 0N, 0O	Wang, Huitao, 14
Guo, Qinghua, 0S	Wang, Jian, 0A
Guo, X. J., 07	Wang, LiMing, 0V
He, Jian-Jun, 12, 15	Wang, Qi, 0N
Huang, Ningbo, 0N	Wang, Wei, 14
Ji, Chen, 14	Wang, Wenting, 0O
Jiang, Maohua, 0X	Wang, Y. F., 07, 0Q
Kan, Qiang, 0Z	Wang, Yani, 0H
Li, Chuanchuan, 10	Wu, Zheng-Mao, 06
Li, Heping, 0P	Xi, Jiangtao, 09, 0S
Li, Jianfeng, 0P	Xia, Guang-Qiong, 06
Li, Jianqiang, 0K	Xing, Junliang, 10
Li, Wei, 0E	Xu, Kun, 0K
Liang, Song, 0Z	Xu, Yingqiang, 10
Liao, Xiaolu, 15	Xu, Yun, 10
Liao, Yongping, 10	Yang, Hua, 02
Liu, Jianguo, 0N, 0O	Yang, Mingqi, 02
Liu, L., 07, 16	Yao, Tingfeng, 0C
Liu, Shuang, 0H	Ye, Huiying, 09
Liu, Yong, 08, 0H, 0P	Yin, Chunjing, 0K
Liu, Y., 16	Yin, Feifei, 0K
Liu, Zhenghao, 0S	Ying, Chaofu, 0V
Lu, Dan, 0T	Yu, Hongyan, 0Z
Lu, Jun, 13	Yu, Jianjun, 0L
Meng, Jianjun, 15	Yu, Liqiang, 0T
Mi, Junping, 0Z	Yu, Luohong, 0P
Morrissey, Padraic, 02	Yu, Yanguang, 09, 0S
Niu, Zhichuan, 10	Yuan, Lijun, 0Z
Pan, Biwei, 0T	Zhang, Junwen, 0L
Pan, Jiaoqing, 0Z	Zhang, Peng, 0X

Zhang, Ruikang, 14
Zhang, Shangjian, 08, 0H
Zhang, Yali, 08, 0H
Zhang, Yu, 10
Zhang, Zhiyao, 0P
Zhao, Lingjuan, 0T, 14
Zhao, P. C., 0Q
Zheng, W. H., 07, 0Q, 16
Zhou, Daibing, 14
Zhou, Xiaojun, 0P
Zhou, Yating, 13
Zhu, Dan, 0C
Zhu, Hong, 13
Zhu, Hongliang, 14
Zhu, Ninghua, 0N, 0O
Zhu, Renjiang, 0X
Zou, Xinhai, 0H

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- 1 Semiconductor Lasers
Werner H. Hofmann, Technische Universität Berlin (Germany)
- 2 VCSELs
Hua Yang, Tyndall National Institute (Ireland)
- 3 Optical Injection of Semiconductor Lasers
Ming Li, Institute of Semiconductors (China)
- 4 Microwave Photonics I
Ming Li, Institute of Semiconductors (China)
- 5 Microwave Photonics II
Shilong Pan, Nanjing University of Aeronautics and Astronautics
(China)
- 6 Optical Communications
Jianqiang Li, Beijing University of Posts and Telecommunications
(China)
- 7 Laser Applications I
Hong-Bo Sun, Jilin University (China)
- 8 Laser Applications II
Yali Zhang, University of Electronic Science and Technology
of China (China)